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(maximum) x 200 μm (minimum). The foil is manufactured by electroforming in one piece and is open at its base. By virtue of its shape, the foil has an arcuate longitudinal centre line, like a banana, and may be a sector of a torroid.--

Replace the paragraph beginning at page 10, line 32 with the following:

--Figs. 10 to 22 show a modified embodiment of the invention including a straight shaving foil 100 having a parabolic shaving surface and closed elliptic end cheeks 101, 102. Fig. 11 shows a longitudinal sectional view taken along line A - A of Fig. 10. The view of Fig. 11 shows the undercutter 181, which is constructed in a substantially conventional way. Fig. 12 is a cross-section taken along line B - B of Fig. 11.--

Replace the paragraph beginning at page 22, line 19, with the following:

--5.2 As shown in Fig. 32, develop the mandrel pattern in "Developer" 41 while stirring with a stirrer 42 and at 20-50°C, preferably 26°C until the aperture pattern is just visible; note the time taken and continue the immersion for the same period.--

Replace the paragraph beginning at page 23, line 1, with the following:

--Fig. 27 shows the mask 242 with its foil aperture pattern 244. Fig. 28 shows the polished mandrel 261 coated with photoresist ready to receive the mask 242.--

In the claims:

Please amend claim 22 as follows:

- -- 22. (Twice Amended) A method of producing an electroformed shaving cutter comprising:
 - a) providing a substrate that has an electrically conductive surface;
- b) applying a coating of electrophoretic photoresist to the electrically conductive surface by passing an electrical current therethrough;
- c) exposing the photoresist to a suitable source of electromagnetic radiation through a mask that is shaped to conform to that of said electrically conductive surface of said substrate;

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d) developing the photoresist; and

e) electrodepositing a metallic layer onto conductive surface regions of the substrate not coated with the photoresist.--

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Please add claim 41.

-- 41. (New) A method according to claim 22, wherein the step of applying further comprises applying the electrophoretic photoresist as a liquid. --

In the drawings:

Please substitute the attached sheets of drawings containing modified Figs. 11, 12, 18, 27, and 32 for the corresponding sheets of drawings presenting those figures as originally filed.

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